# Kinetics of ordering and metastable phase of alloys

#### Jun Ni Department of Physics Tsinghua University



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Dr.Z.H.Dai, Y.L.Xu, H.T.Shi L. Shi, X.B.Yang, Z.Q.Liu, Y.Sun, Y.L.Wang J.L.Pan, Y.Ding,Z.J.Xu

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#### References

- L. Shi and J. Ni, Phys. Rev. Lett. 97, 126105 (2006).
- Z. Q. Liu and J. Ni, J.Phys.: Condens. Matter 17, 5355 (2005).
- L. Shi and J. Ni, Phys. Rev. B 69, 155428 (2004).
- L. Shi, H. T. Shi, and J. Ni, Comp. Materials Science 30, 326-330 (2004).



Introduction
 Kinetics Phase Diagram in alloy growth
 Kinetics of ordering during alloy film growth
 Summary

### Introduction

- Non-equilibrium growth: rapid quench, laser treatment, ion bombartment, and various epitaxial growth methods for the growth of materials in non-equilibrium state and metastable state.
- It is important to understand the basic kinetic processes during the growth. The equilibrium phase diagrams can not deliver enough information on non-equilibrium growth.

### Methods

**Kinetic process** 

- PPM method
- Master equation method
- Monte-Carlo method

**Energy parameters** 

First principle methods

### Introduction

- CEpitaxial growth (MBE、MOCVD): layer by layer growth.
- Fcc ordering: Ordering structures in metal alloys: CuAu; CoPt; FePt;
- III-V semiconductor alloys,

# Kinetical phase diagram



Phase diagram with temperature and ratio  $\kappa$  as parameters

$$U_0 = 1.0, \quad \mu_A = \mu_B = 0.25, \quad P_A^{\alpha} = P_A^{\beta} = 1.0, J = 1$$

### Oscillated ordering



Kinetical induced oscillated ordering

 $k_B T / J = 0.06$ ,  $\kappa = 5 \times 10^{-3}$ ,  $U_0 = 0.8$ ,  $\mu_A = \mu_B = 0.25$ ,  $P_A^{\alpha} = P_A^{\beta} = 1.0$ 

#### Nearest neighbor interaction



 $\kappa = 5 \times 10^{-3}$ ,  $U_0 / J = 1.0$ ,  $\mu_A = \mu_B = 0.025 eV$ 

# Kinetic phase diagrams of epitaxial growth for SiC polytypes

- The most common polytypes are zinc-blende SiC (3C-SiC), wurtzite SiC (2H-SiC), 4H-SiC,6H-SiC, and 15R-SiC.
- The origin of polytypism in SiC is still not completely understood. The polytypes should be viewed as the non-equilibrium structures arising from special growth mechanisms
- Generalized a stable phase. But it is easyly grown by



#### Kinetic phase diagrams of SiC epitaxial growth



the rearrangement of atoms in one surface bilayer is allowed

the rearrangement of atoms in two surface bilayer is allowed

#### Kinetic phase diagrams of SiC epitaxial growth



the rearrangement of atoms in

the rearrangement of atoms in six

#### The CoPt alloy films

- We consider an fcc film of CoPt alloy grown in the [001] direction on the buffer layer is Pt layer
- 2 The order parameter in the [100] direction is:  $\eta_{[100]}(m) = P^{\alpha}_{Co}(m) - P^{\beta}_{Co}(m)$
- 3 The order parameter in the [001] direction is:  $\eta_{[001]}(m) = |x_{Co}(m) - x_{Pt}(m)|$
- the total energies of structures calculated by VASP.
- The kinetic equations of growth consist of all the three contributions from the diffusion, evaporation, and adsorption processes

$$\frac{dP_i^s(m)}{dt} = \sum_j \sum_{s'} (Y_{ji}^{ss'} - Y_{ij}^{ss'}) + Z_i^s(m) + X_i^s(m)$$

#### Ordering of the CoPt alloy films

#### The experiment result and simulation result:



The average order parameter in the [001] direction as a function of temperature with  $\kappa = 5.0 \times 10^{-6}$ , where square dots are the experiment data. (O. Ersen, et al. J. Appl. Phys.

93, 2987 (2003).)

# Variation of order parameters with the increase of growth rate



The average order parameters of 8 layer films as a function of & with T=570 K

L. Shi and J. Ni, Phys. Rev. Lett. 97, 126105 (2006).

# Variation of order parameters with temperature



The average order parameters of 8 layer films as a function of temperature

#### Ordering orientation superlattice





(a) The superlattice with the ordering-orientation transition per 12 layers.(b) The order parameters of the ordering orientation superlattice.

L. Shi and J. Ni, Phys. Rev. Lett. 97, 126105 (2006).

#### Summary

- Kinetics of ordering in alloy films and Kinetic phase diagrams, there is an oscillated ordered phase with occurrence conditions of high deposition rate
- The 3C-SiC phase would grow epitaxially in low temperature. The 4H-SiC phase would grow epitaxially in intermediate temperature. The 6H-SiC or 15R-SiC phases would grow epitaxially in higher temperature. This is in agreement with experiments
- We have investigated the effect of the kinetic anisotropy on the formation of structures in the epitaxial growth of alloy films. the ordering orientation of the L1<sub>0</sub> ordered structure changes from the [001] direction to the [100] direction with the increase of the growth rate.
- We propose a simple method to synthesize the ordering orientation surperlattice by periodically changing the growth rate.

# Thank You

#### Master equation method

Master equation method  $\frac{d}{dt} P_{\alpha_i}(\vec{r}_i, t) = \sum_{j \neq i} \sum_{\{x\}} R_{\alpha_j, \alpha_i, \{x\}}(\vec{r}_i, \vec{r}_j, \{\vec{x}\}) P_{\alpha_j, \alpha_i, \{x\}}(\vec{r}_i, \vec{r}_j, \{\vec{x}\}) \\
-\sum_{j \neq i} \sum_{\{x\}} R_{\alpha_i, \alpha_j, \{x\}}(\vec{r}_i, \vec{r}_j, \{\vec{x}\}) P_{\alpha_i, \alpha_j, \{x\}}(\vec{r}_i, \vec{r}_j, \{\vec{x}\}) \\
P_{\alpha_1, \dots, \alpha_n}(r_1, \dots, r_n; t): \text{ cluster probability} \\
R_{\alpha_1, \dots, \alpha_n}(r_1, \dots, r_n; t): \text{ exchange rate.}$ 

 $\langle x \rangle$ : neighboring cluster of interacting neighborhood.

# Oscillatory ordered phase



 Effects of underlayer on the broken factor

Ordering in the odd layers

 $k_B T / J = 0.06$ ,  $\kappa = 5 \times 10^{-3}$ ,  $U_0 = 0.8$ ,  $\mu_A = \mu_B = 0.25$ ,  $P_A^{\alpha} = P_A^{\beta} = 0.5$ 

# Kinetic phase diagram



Phase diagram with temperature and energy barrier as parameters  $\kappa = 5 \times 10^{-3}, \quad \mu_A = \mu_B = 0.25, \quad P_A^{\alpha} = P_A^{\beta} = 1.0$